

10/566750

IAP2004/010714 01 FEB 2006
OGOSH45USA

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:)	
)	Examiner:
Yuichiro Shindo et al.)	
)	Group Art Unit:
Application No.:)	
)	
Corresponding International Filing No.:)	
PCT/JP2004/010714)	
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Filed: Herewith)	
)	
For: HIGH PURITY COPPER)	
SULFATE AND METHOD FOR)	
PRODUCTION THEREOF)	

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

SECOND PRELIMINARY AMENDMENT

Sir:

Please amend the above-identified patent application as follows.

Amendments to the Specification begin on page two of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on
page four of this paper.

Remarks begin on page six of this paper.